



Docket No. 0524-0140.01

AF
Ifw

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)

Nozawa et al.)

Serial No.: 10/667,823)

Filed: September 22, 2003)

For: Phase Mask Shift Blank, Photo Mask Blank,)
And Manufacturing Apparatus And Method)
Of Blanks)

Examiner: Rodney Glenn McDonald)

Art Unit: 1753)

Commissioner of Patents
P. O. Box 1450
Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited
with the United States Postal Service as first class mail in an
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January 23 2006
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Shannon Wallace

Name of applicant, assignee, or Registered Rep.

Shannon Wallace
Signature

1/23/06
Date

AMENDMENT (C) AFTER FINAL

Dear Sir:

In response to the Final Rejection of October 24, 2005, please enter the following amendment
in the above-identified application:

*entered per Rec
filed 2/27/06
na*